

AUDIX Technology (Shenzhen) Co., Ltd. No. 6, Kefeng Road, Science & Technology Park, Nanshan District, Shenzhen, Guangdong, China Tel: 0755-26639495~6-7 Fax: 0755-26632877

Technical Compliance

No. ACS-E23150

The following product has been tested by us with the listed standards and found in compliance with the council EMC directive 2014/30/EU. It is demonstrative for the compliance with this EMC Directive.

Applicant : BITMAIN DEVELOPMENT PTE. LTD.

1 Raffles Place, #36-01 One Raffles Place, Singapore 048616

Product : SERVER

Model No. : D9

CE

| | Test Standards: | |
|--|--|-------------------------------------|
| EN 55032: 2015+A11: 2020 (Class A) EN 55032: 2015 | Electromagnetic compatibility of multimedia equipment - Emission requirements | |
| EN IEC 61000-3-2: 2019 | Electromagnetic compatibility(EMC) Part 3-2:Limits-Limits for harmonic current emissions(equipment input current ≤16A per phase) | |
| EN 61000-3-3: 2013+A1: 2019 | Electromagnetic compatibility(EMC) Part 3-3:Limits-Limitation of voltage changes, voltage fluctuations and flicker in public low-voltage supply systems, for equipment with rated current <16A per phase and not subject to conditional connection | |
| EN 55035: 2017 EN 55035: 2017+A11: 2020 | Electromagnetic compatibility of multimedia equipment — Immunity requirements | |
| | IEC 61000-4-2: 2008 | Electrostatic Discharge |
| | IEC 61000-4-3: 2006+A1: 2007+A2: 2010 | RF Field Strength Susceptibility |
| | IEC 61000-4-4: 2012 | Electrical Fast Transients |
| | IEC 61000-4-5: 2014+A1: 2017 | Surge |
| | IEC 61000-4-6: 2013 | Continuous Conducted disturbance |
| | IEC 61000-4-8: 2009 | Magnetic Field Immunity |
| | IEC 61000-4-11: 2004+A1: 2017 ® A | Dips Voltage Interruption Variation |

HUDIX

Audix Technology (Shenzhen) Co., Ltd.

EMC部門報告専用章

Stamp only for EMC Dept. Report

Signature:

David Jin

Deputy General Manager

Date: Oct.07, 2023

The technical compliance is based on a single evaluation of one sample of above mentioned product. It does not imply an assessment of the whole production and does not permit the use of the test lab. logo.